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02/28/02

U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10084456	FILING DATE 02/28/2002	CLASS 528	SUBCLASS	GAU 1712	EXAMINER
**APPLICANTS: Kobayashi Toshiaki; Hayashi Teruyuki; Tanaka Masato;					
**CONTINUING DATA VERIFIED: <i>None</i> <i>KLP</i>					
** FOREIGN APPLICATIONS VERIFIED: <i>yes</i> JAPAN 2001-091159 03/27/2001 <i>KLP</i>					
PG-PUB DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO			
35 USC 119 conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no					
Verified and Acknowledged Examiner's initials <i>KLP</i>					
TITLE : Silsesquioxane polymer molding and method of preparing same					

U.S. DEPT. OF COMMERCE PAT. & TM. PTO-435 (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Assistant Examiner	
ISSUE FEE		Total Claims	
Amount Due	Date Paid	Print Claim for O.G.	
		DRAWING	
		Sheets Drwg.	
		Figs. Drwg.	
		Print Fig.	
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner	
		Application Examiner	
		PREPARED FOR ISSUE	
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